

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

June 3, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

LG712587796

LABORATORY GROWN DIAMOND

EMERALD CUT

7.10 X 5.09 X 3.06 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.10 CARAT

D

INTERNALLY FLAWLESS

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

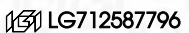
EXCELLENT

EXCELLENT

NONE

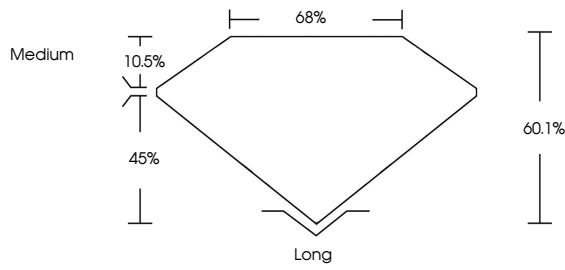
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

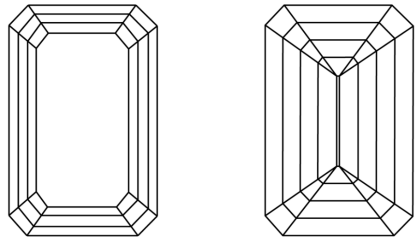


Report verification at igi.org

PROPORTIONS




CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.



Sample Image Used

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

IF

VS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³



Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included


Included



© IGI 2020, International Gemological Institute

FD - 10 20

LABORATORY GROWN DIAMOND REPORT



June 3, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

LG712587796

LABORATORY GROWN DIAMOND

EMERALD CUT

7.10 X 5.09 X 3.06 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.10 CARAT

D

INTERNALLY FLAWLESS

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

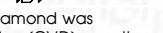
EXCELLENT

EXCELLENT

NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



June 3, 2025

IGI Report No LG712587796

EMERALD CUT

7.10 X 5.09 X 3.06 MM

Carat Weight

Color Grade

Clarity Grade

Depth

Table

Girdle

1.10 CARAT

D

IF

60.1%

65%

Medium

Long

EXCELLENT

EXCELLENT

NONE

IGI LG712587796

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

IGI LG712587796

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa